

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

## Title of Invention

METHODS FOR HIGH-PRECISION GAP AND ORIENTATION  
SENSING BETWEEN A TRANSPARENT TEMPLATE AND  
SUBSTRATE FOR IMPRINT LITHOGRAPHY

Application Number : 09/920341  
Confirmation Number: 4146  
First Named Applicant: Byung Choi  
Attorney Docket Number: PA17-07V06  
Art Unit: 2877  
Examiner: Sang H. Nguyen  
Search string: ( 5414514 or 5808742 or 6522411 ).pn



## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
SN	1	5414514	1995-05-09	Smith et al.			
SN	2	5808742	1998-09-15	Everett et al.			
SN	3	6522411	2003-02-18	Moon et al.	B1		

## Signature

Examiner Name	Date
<i>Sang H. Nguyen</i>	04/28/05

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SN	1	6190929	2001-02-20	Wang et al.	B1		

## Signature

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<i>Sang H. Nguyen</i>	04/28/05